Current US Cross Reference Classification - CCXR (3): 428/349

Current US Cross Reference Classification - CCXR (4): 428/354

Current US Cross Reference Classification - CCXR (5): 428/474.4

L Number	· Hits	Search Text	DB	Time stamp
1	132	(barrier same (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:19
			US-PGPUB;	
1			EPO; JPO;	
			DERWENT	
2	73	((barrier same (ion\$3 adj3 chlori\$3))) and electron\$3	USPAT;	2004/04/21 06:47
			US-PGPUB;	200.701721 00.47
			EPO; JPO;	
			DERWENT	
3	29	(((barrier same (ion\$3 adj3 chlori\$3))) and electron\$3)		2004/04/21 07:04
3	29		USPAT;	2004/04/21 07:04
		and ppm	US-PGPUB;	
			EPO; JPO;	
		/// L L // 42 U2 LL 440V	DERWENT	
4	655	((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)	USPAT;	2004/04/21 07:22
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
5	0	(((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)) and	USPAT;	2004/04/21 07:20
		impurit	US-PGPUB:	
			EPO; JPO;	
			DERWENT	
6	115	(((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)) and	USPAT;	2004/04/21 07:20
	1,13	impurit\$3	US-PGPUB;	2004/04/21 07.20
		Impuncas		
			EPO; JPO;	
-	60	////intrand/inata adia aldanita)\\ -	DERWENT	2004/04/03 05 55
7	69	((((((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)) and	USPAT;	2004/04/21 07:20
		impurit\$3) and (circuit IC electronic))	US-PGPUB;	
			EPO; JPO;	
_			DERWENT	
8	26310	(((((((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)) and	USPAT;	2004/04/21 07:21
		impurit\$3) and (circuit IC electronic))) and receiving	US-PGPUB;	
		receptive	EPO; JPO;	
	,		DERWENT	
9	19	(((((((ink and (ion\$3 adj3 chlori\$3)) and electron\$3)) and	USPAT;	2004/04/21 07:21
		impurit\$3) and (circuit IC electronic))) and (((((((ink and	US-PGPUB:	, , , , , , , , , , , , , , , , , , , ,
		(ion\$3 adj3 chlori\$3)) and electron\$3)) and impurit\$3)	EPO; JPO;	
		and (circuit IC electronic))) and receiving receptive)	DERWENT	
10	3776870	((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 07:22
		electron\$3 IC circuit)	US-PGPUB;	2001/01/21 07:22
			EPO; JPO;	
			DERWENT	
11	151509	(((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 07:24
'	151509	electron\$3 IC circuit)) and card		2004/04/21 07:24
		Ciccionas ic circuis) and card	US-PGPUB;	
*			EPO; JPO;	
1.2	7017	////	DERWENT	
12	7917	((((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 07:24
		electron\$3 IC circuit)) and card) and concentration	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
13	3	((((((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 07:25
		electron\$3 IC circuit)) and card) and concentration)	US-PGPUB;	
		and resin same (ion\$3 adj3 chlori\$3))	EPO; JPO;	
		· · ·	DERWENT	
14	1	(235/487.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:26
			US-PGPUB;	
			EPO; JPO;	
		V	DERWENT	
15	0	(283/904.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:26
	J	(Les, so needs, and hones aujs emones))	US-PGPUB;	2004/04/21 07:20
*			EPO; JPO;	
			DERWENT	L

	Ţ,	(257/701	LUCBAT	2004/04/23 07 20
16	1	(257/791.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:28
			US-PGPUB;	
			EPO; JPO;	
		(400,400, 1, 1, 1, 1, 1, 1, 1, 1, 1, 1, 1, 1, 1,	DERWENT	
17	0	(428/195.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:42
	1		US-PGPUB;	
			EPO; JPO;	
			DERWENT	
18	0	(428/204.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:28
			US-PGPUB;	
			EPO; JPO;	
	1		DERWENT	
19	518	(428/\$.ccls. and (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:28
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
20	46	(((428/\$.ccls. and (ion\$3 adj3 chlori\$3))) and (IC	USPAT;	2004/04/21 07:29
		electronic circuit) and ink)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
21	0	5328750.URPN.	USPAT	2004/04/21 07:34
22	23	4457972.URPN.	USPAT	2004/04/21 07:38
23	65	(adhesive same (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:54
			US-PGPUB;	
			EPO; JPO;	
l _			DERWENT	
25	0	((wafer same (ion\$3 adj3 chlori\$3))) and ink	USPAT;	2004/04/21 07:54
			US-PGPUB;	
	·		EPO; JPO;	
1			DERWENT	
24	90	(wafer same (ion\$3 adj3 chlori\$3))	USPAT;	2004/04/21 07:54
			US-PGPUB;	-
			EPO; JPO;	
			DERWENT	

2004/04/21 08:14 2004/04/21 08:04 2004/04/21 08:16 2004/04/21 08:05 2004/04/21 08:15 2004/04/21 08:15
2004/04/21 08:16 2004/04/21 08:05 2004/04/21 08:15 2004/04/21 08:15
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2004/04/21 09:59
2004/04/21 08:58
2004/04/21 08:58

43	((((ionic adj3 impurit\$4) with (adhesive epoxy))) and (ion\$3 adj3 chlori\$3))	USPAT; US-PGPUB:	2004/04/21 08:59
		EPO; JPO;	
*		DERWENT	

L Number	Hits	Search Text	DB	Time stamp
30	1797734	(resin polymer same (alkali acid adj3 resistance))	USPAT;	2004/04/21 08:15
		, and the second	US-PGPUB;	
			EPO; JPO;	
		· ·	DERWENT	
31	92917	((resin polymer) same (alkali acid adj3 resistance))	USPAT;	2004/04/21 08:15
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
32	65167	((resin polymer) with (alkali acid adj3 resistance))	USPAT;	2004/04/21 08:15
_	7		US-PGPUB;	
		0	EPO; JPO;	
			DERWENT	
33	12905	(((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 08:16
33	,	electron\$3 IC circuit)) and (((resin polymer) with (alkali	US-PGPUB;	·
		acid adj3 resistance)))	EPO; JPO;	
		30.2 3.3 3.3 3.3 3.3 3.3 3.3 3.3 3.3 3.3 3	DERWENT	
34	6899	(((((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 08:16
J.		electron\$3 IC circuit)) and (((resin polymer) with (alkali	US-PGPUB;	
		acid adj3 resistance)))) and (purity impuritity ion\$3))	EPO; JPO;	
		dera days resistanteey,,, and (parter) imparter,	DERWENT	
35	400	(((((((resin polymer same (ion\$3 adj3 chlori\$3)) and	USPAT;	2004/04/21 08:16
33	400	electron\$3 IC circuit)) and (((resin polymer) with (alkali	US-PGPUB;	2001,01,2100112
		acid adj3 resistance)))) and (purity impuritity ion\$3)))	EPO; JPO;	
		and (ion\$3 adj3 chlori\$3))	DERWENT	
36	38		USPAT;	2004/04/21 08:54
30	36	electron\$3 IC circuit)) and (((resin polymer) with (alkali	US-PGPUB;	2001/01/21 00:51
		acid adj3 resistance)))) and (purity impuritity ion\$3)))	EPO; JPO;	
	*	and (ion\$3 adj3 chlori\$3))) and ((428/\$.ccls. and	DERWENT	
		(ion\$3 adj3 chlori\$3)))	DERWENT	
37	3	1	USPAT	2004/04/21 08:51
38	7	("4070225" "4082708" "4171404" "4273916"	USPAT	2004/04/21 08:52
36	′	"4707388" "5001542" "5290614").PN.	OSIAI	2001/01/21 00.32
30	,	"4400229".PN.	USPAT	2004/04/21 08:54
39	236	((ionic adj3 impurit\$4) with (adhesive epoxy))	USPAT;	2004/04/21 08:55
40	230	((lottic adj3 illipulits4) with (adilesive epoxy))	US-PGPUB;	2004/01/21 00.33
			EPO; JPO;	
			DERWENT	
41	112	((((ionic adj3 impurit\$4) with (adhesive epoxy))) and	USPAŢ;	2004/04/21 08:55
41	112	(circuit IC memory non\$contact))	US-PGPUB;	2004/04/21 00.33
		(circuit ic memory nonscontact))	EPO; JPO;	
			DERWENT	
43	11	(((((((ionic adj3 impurit\$4) with (adhesive epoxy))) and	USPAT;	2004/04/21 08:58
42	11	(circuit IC memory non\$contact))) and (ion\$3 adj3	US-PGPUB;	2004/04/21 00.30
1			EPO; JPO;	
		chlori\$3))		
1 43	33	((((ionic adi2 impurit\$4) with (adhasive enevy))) and	DERWENT	2004/04/21 09:08
43	33	,,,,,	USPAT;	2004/04/21 09.00
1		(ion\$3 adj3 chlori\$3))	US-PGPUB;	
			EPO; JPO;	
		/ MA (A) (Cambo adop obligado) and adhirit	DERWENT	2004/04/21 00:15
44	47	(remov\$4 with (ion\$3 adj3 chlori\$3)) and adhesive	USPAT;	2004/04/21 09:15
		·	US-PGPUB;	
			EPO; JPO;	
		· ·	DERWENT	